

DETECTORS FOR HIGH ENERGY PHYSICS

Part 3



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OVERVIEW

- I. Detectors for Particle Physics
- II. Interaction with Matter
- III. Calorimeters

IV. Tracking Detectors

- Semiconductor trackers
- Gas detectors
- Muon detectors
- V. Examples from the real life

Tuesday

Wednesday



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IV. TRACKING DETECTORS

VHOET, S, C

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TRACKING

• "tracking" in google image search:











CARGO

TRACKING DETECTOR

• "tracking detector" in google image search



GPS Tracking Detector



Online Multi-Person Track from a Single, Uncalibrate

But the 1st image on list is:





TRACKING DETECTORS

- Precise measurement of track and momentum of charged particles due to magnetic field.
- The trajectory should be disturbed minimally by this process (reduced material)

- Charged particles ionize matter along their path.
 - Tracking is based upon detecting ionisation trails.
 - An "image" of the charged particles in the event



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TRACKING DETECTORS - TECHNOLOGIES

- "Classic": Emulsions, cloud, and bubble chambers
 - Continuous media
 - Typically very detailed information but slow to respond and awkward to read out
- **"Modern":** Electronic detectors, wire chambers, scintillators, solid state detectors
 - Segmented
 - Fast, can be read out digitally, information content is now approaching the "classic" technology
 - Mostly used solid state detector -> Silicon (pixels and strips)







CMS Inner barrel Si Tracker: Single-Sided Si-Strip



Discovery of neutral currents Gargamelle, 1972



Pictures: CERN

VERY "CLASSIC": BUBBLE CHAMBER



Early report on bubble chamber analysis:



Second United Nations International Conference on the Peaceful Uses of Atomic Energy

A/CONF.15/P/730 U.S.A. June 1958 ORIGINAL: ENGLISH

ON THE ANALYSIS OF BUBBLE CHAMBER TRACKS

Hugh Bradner and Frank Solmitz

"... the large number of possible reactions, the variability of appearance of interaction, and the importance of being alert to possible new phenomena make it very important for a trained physicist to look at the bubble chamber pictures...."

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TRACKER: IMPORTANT PARAMETER

- An important figure of merit is the spatial resolution of a tracking detector
- Depending on detector geometry and charge collection
 - Pitch (distance between channels)
 - Charge sharing between channels
 - Simple case: all charge is collected by one strip
 - Traversing particle creates signal in hit strip (binary)
 - Flat distribution along strip pitch; no area is pronounced
 - ➔ Probability distribution for particle passage:



The reconstructed point is always the middle of the strip:

$$\langle x \rangle = \int_{-d/2}^{d/2} x P(x) \, dx = 0$$





pitch





TRACKER: IMPORTANT PARAMETER

Calculating the resolution orthogonal to the strip:

$$\sigma_x^2 = \left\langle (x - \langle x \rangle)^2 \right\rangle = \int_{-d/2}^{d/2} x^2 P(x) \, dx = \frac{d^2}{12}$$

Resulting in a general term (valid for tracking detectors with a pitch d):



- For a silicon strip detector with a strip pitch of 80 µm this results in a minimal resolution of ~23µm
- In case of charge sharing between the strip (signal size decreasing with distance to hit position) and information about signal size
 - resolution improved by additional information of adjacent channels



ATLAS/CMS Pixels $\sigma_{\mathrm{r}\phi} \approx 10 \mu m$



TRACKING: MOMENTUM IN MAGNETIC FIELD

- A tracking detector is typically placed within a B-field to enable momentum measurements
- Charged particles are deflected in a magnetic field:
 - takes only effect on the component perpendicular to the field

Radius of the circular path is proportional to the transversal momentum

$$F = qvB$$
$$ma = qvB$$
$$m(\frac{v^2}{r}) = qvB$$
$$p = 0.3Br$$

when converting in HEP units and assuming that all particles have the |electron charge|

- parallel to the field is no deflection:
 - \Rightarrow particle is moving on a helix, the radius is determined by the field and p_T



MOMENTUM IN MAGNETIC FIELD II

- In real applications usually only slightly bent track segments are measured
 - Figure of merit: sagitta



Momentum resolution due to position measurement:





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MOMENTUM RESOLUTION

- Precise measurement of track and momentum of charged particles due to magnetic field.
- The trajectory should be disturbed minimally by this process (reduced material)
 - Momentum resolution depending on many factors:

When designing a tracking detector one should well understand what is required for the processes to be observed.

Ideal (non-realistic) tracking detector:

a massless, cheap, infinite granularity, 100% hermetic and efficient, infinite, long lifetime detector



NIM, 24, P381, 1963

B = magnetic field
 n = number of
 measurement points
 L = length (~radius)
 = spatial resolution

TRACKER: IMPORTANT PARAMETER



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TRACKER: IMPORTANT PARAMETER

- **Signal/noise ratio**: signal size for a certain input signal over the intrinsic noise of the detector
 - parameter for analog signals
 - good understanding of
 electrical noise charge needed
 - leakage current (ENC_I)
 - detector capacity (ENC_C)
 - det. parallel resistor (ENC_{Rp})
 - det. series resistor (ENC_{Rs})
 - signal induced by source or laser (or test beam particles)
 - optimal S/N for a MiP is larger than 20

$$ENC = \sqrt{ENC_C^2 + ENC_I^2 + ENC_{R_p}^2 + ENC_{R_s}^2}$$

example for silicon detector

With analog readout:

Gaussian distributed "non-signal" = sigma -> noise







IMPACT PARAMETER RESOLUTION

 $(p \cdot Side Point$

Collision

12/12/2012

influence of nultipleetector

scatteringer(ge) metry)

for 100GeV track

polar angle

Impact parameter resolution = shortest distance between the reconstructed track and the associated primary vertex



Tracks



ATLAS $\sigma_{\rm IP} > 10 \mu m$

 $\sigma_{r\phi}^2 = \sigma_{rz}^2 = a^2 + b^2 \cdot$

intrinsic resolution of the tracking

system (no multiple scattering)

IV.A SEMICONDUCTOR-DETECTORS

VIFICET, S, C

LARGE SILICON SYSTEMS



Since ~ 30 years: Semiconductor detectors for precise position measurements.

DELPHI (1996)

- $\sim 1.8m^2$ silicon area
- ~ 175 000 readout channels





SEMICONDUCTOR BASICS

- In free atoms electron energy levels are discrete.
- In a solid, energy levels split and form a nearly-continuous band.



Intrinsic charge carrier

~4 x 10⁸ electron/hole pairs

300µm

- Large gap: the solid is an insulator.
- No gap: it is a conductor.
- Small band gap: semiconductor
- For silicon, the band gap is 1.1 eV, but it takes 3.6 eV to ionise an atom
 - Remaining energy goes to phonon excitations (heat).

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DOPING SILICON





n type semiconductor:

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- Negative charge carriers (electrons) by adding impurities of donor ions (e.g. Phosphorus (type V))
- Donors introduce energy levels close to conduction band thus almost fully ionised (E_F closest to CB)

Electrons are the majority carriers.

p type semiconductor:

- Positive charge carriers (holes) by adding impurities of acceptor ions (e.g. Boron (type III)).
- Acceptors introduce energy levels close to valence band thus 'absorb' electrons from VB, creating holes (E_F closest to VB).

Holes are the majority carriers.

BASIS OF SILICON DETECTOR: PN JUNCTION

- At interface of p type and n type semiconductor difference in the Fermi levels causes diffusion of excessive carriers to the other material until thermal equilibrium is reached.
- Stable space charge region free of charge carriers is called **depletion zone**.
- Typical current-voltage of a p-n junction: exponential current increase in forward bias, small saturation in reverse bias.



Applying an external voltage V with the cathode to p and the anode to n (reverse biasing), e-h pairs are pulled out of the depletion zone. \rightarrow larger depletion zone \rightarrow suppress current across the junction

pn-junction with reverse bias



UN

PRINCIPLE OF SEMICONDUCTOR DETECTORS

Creation of electric field: voltage to deplete thickness d

with
$$n_A >> n_D$$
 $d = \sqrt{\frac{2\epsilon\epsilon_0 V_{dep}}{en_D}}$

for $d = 300 \mu m$: $V_{dep} \approx 160 V$

- Passage of a charged particle: Electron-hole pairs formed in the depletion zone
 - Drift under the influence of the electric field
 - Signal depends on width of depletion zone

The signal is induced by the motion of charge after incident radiation (not when the charge reaches the electrodes).





CURRENT DENSITY





Simulation: Thomas Eichhorn

MATERIAL PROPERTIES

| | Si | Ge | GaAs | CdTe | Diamond | SiC |
|--------------------------|-------|-------|-------|-------|---------|-------|
| band gap | 1.12 | 0.67 | 1.42 | 1.56 | 5.48 | 2.99 |
| energy for e-p pair [eV] | 3.6 | 2.9 | 4.2 | 4.7 | 13.1 | 6.9 |
| e- for MIP (300µm) | 24000 | 50000 | 35000 | 35000 | 9300 | 19000 |
| Z | 14 | 32 | 31+33 | 48+52 | 6 | 14+6 |

Why is silicon used more often ?

- Silicon is the only material which can be produced in larger areas in high quality
- compare to kT = 0.026 eV at room temperature -> dark current under control
- high density compared to gases: ρ=2.33g/cm³
- good mechanical stability -> possible to produce mechanically stable layers
- large charge carrier mobility
- fast charge collection δt~10ns
 - well understood -> radiation tolerant





PROBLEM: RADIATION DAMAGE

- Radiation damages the silicon on atomic level significantly leading to macroscopic effects.
- Surface effects: Generation of charge traps due to ionising energy loss — Total ionising dose, TID (problem for sensors and readout electronics).
 - Cumulative long term trapping of positive charge
 - Increase of leakage current and oxide breakdown



STI = shallow trench interface

- Bulk effects: displacement damage and build up of crystal defects due to non ionising energy loss (NIEL) (main problem for sensors).
 - Unit: 1MeV equivalent n/cm²



Defects composed of: Vacancies and Interstitials

Compound defects with impurities possible!

| Detector | NIEL [1MeV n _{eq} /cm ²] | TID [Mrad] | | |
|----------------------------|---|---------------|--|--|
| ALICE ITS | 10 ¹³ | <1 | | |
| Belle II (per year) | 1.2x10 ¹³ | 1.9 | | |
| ATLAS/CMS Outer Tracker | 10 ¹⁵ | <100 | | |
| ATLAS/CMS Inner Tracker | 10 ¹⁶ | 1000 | | |

RADIATION DAMAGE: MACROSCOPIC EFFECTS

Impact of defects on detector properties depends on defect level in band gap





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RADIATION DAMAGE: MACROSCOPIC EFFECTS

Impact of defects on detector properties depends on defect level in band gap





STRIPS AND PIXELS

- Strips detector: charge sensed by long narrow strips
 1D information (typically 20 100µm)
 - 2D information by double sided processing or adding back to back second layer slightly rotated (stereo angle)
- In regions with higher track density one dimensional measurements can lead to ambiguities.

- Pixel detector: charge sensed by small pixels on one side of sensor
 - Hybrid pixels: sensors and readout joined via bump bonds
 - Monolithic pixels: sensor and readout on one substrate





- Signals created in silicon by charged particle
 - Very small signals (fC): need amplification
 - Measurement of amplitude/hit and/or time (ADCs, discriminators, TDCs)
 - Several thousands to millions of channels

EXAMPLE: CURRENT ATLAS SILICON DETECTOR

- Ourrent tracking detector "the first meter":
 - Silicon pixel detector
 - 4 layers, 8 disks
 - Pixel size: 50 x 400µm² (IBL: 50 x 250µm²)
 - 2000 modules with 140M channels
 - SemiConductor Tracker (SCT)
 - Strips width: 70µm
 - 4088 modules with 6.3M channels, 62m²





SILICON DETECTOR

- Segmented p-n diode with applied bias voltage
- Particle creates charges.
- Free carriers diffuse across junction, electrons neutralising the holes.
- Charges drift to contacts
- Signal is read out.

ATLAS Strip Module







FROM MODULE TO DETECTOR





SCT ENDCAP





SCT BARREL





SILICON TRACKER (SCT)





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Insertion of the 3rd cylinder (out of the four) into the barrel SCT







CMS SI-TRACKER



CMS TRACKER - BEAUTY SHOT





LIMITS OF STRIP DETECTORS



- Deriving the point resolution from just one coordinate is not enough information to reconstruct a secondary vertex
 - Pixel detectors allow track reconstruction at high particle rate without ambiguities
 - Good resolution with two coordinates (depending on pixel size and charge sharing between pixels)
 - Very high channel number: complex read-out
 - Readout in active area a detector



HYBRID PIXELS - "CLASSICAL" CHOICE HEP

- The read-out chip is mounted directly on top of the pixels (bump-bonding)
- Each pixel has its own read-out amplifier
- Can choose proper process for sensor and read-out separately
- Fast read-out and radiation-tolerant

... but:

- Pixel area defined by the size of the read-out chip
- High material budget and high power dissipation





- CMS Pixels: ~65 M channels 150 µm x 150 µm
- ATLAS Pixels: ~80 M channels $50 \ \mu m \ x \ 400 \ \mu m \ (long in z \ or r)$
- Alice: 50 µm x 425 µm
- LHCb
- Phenix@RHIC
-

SENSORS FOR HYBRID PIXELS

Planar Sensor

- current design is an n-in-n planar sensor
- silicon diode
- different designs under study (n-in-n; n-in-p)
- radiation hardness proven up to 2.4 . 10¹⁶ p/cm²
- problem: HV might need to exceed 1000V

Very strong R&D efforts to develop sensors for future LHC applications!

3D Silicon

- Both electrode types are processed inside the detector bulk instead of being implanted on the wafer's surface.
- Max. drift and depletion distance set by electrode spacing
- Reduced collection time and depletion voltage
- Low charge sharing



CVD (Diamond)

 Poly crystalline and single crystal

FE chip

sensor

- Low leakage current, low noise, low capacitance
- Radiation hard material
- Operation at room temperature possible
- Drawback: 50% signal compared to silicon for same X₀ but better S/N ratio (no dark current)





ATLAS-PIXELS

A pixel module contains:

1 sensor (2x6cm) ~40000 pixels (50x500 mm) 16 front end (FE) chips 2x8 array bump bonded to sensor Flex-hybrid 1 module control chip (MCC) There are ~1700 modules





Picture: VTT

UN

ATLAS-PIXELS





MONOLITHIC PIXEL SENSORS

- Some HEP applications (Linear Collider etc.) require extremely good spatial resolution (factor 2-5 better than at LHC) and very low material in the tracker
- Hybrid pixel sensors are too thick for such applications
- Investigating technologies with sensor and readout electronics in one layers -> monolithic
- Four different technologies:
 - CCD, DEPFET, CMOS, and 3D
 - different variants of each technology approach under investigation
- Some of them where chosen as baseline technology for real experiments
 - DEPFET for Belle II @KEK (Japan)
 - Mimosa MAPS for Star @ RHIC (USA)







OVERVIEW OF READOUT ELECTRONICS

Most front-ends follow a similar architecture



- Very small signals (f_c) -> need amplification
- Measurement of amplitude and/or time (ADCs, discriminators, TDCs)
- Several thousands to millions of channels
- Also here very detailed R&D ongoing to adapt to future challenges in HEP
 - more radiation hard, higher occupancy, smaller strip/pixel pitch etc.
 - adapting new CMOS technologies for HEP applications

INDUSTRY SCALING ROADMAP

- New generation every ~2 years with $\alpha = \sqrt{2}$
 - from 1970 (8 μm) to 2013 (22 nm) (industrial application)
- End of the road ? Power dissipation could set limits
- HEP nowadays at 65nm and 130nm
- Problem: by the time a technology is ready for HEP -> "old" in industry standards
- Super expensive



| Feature Size [nm] | 2000 | 1200 | 800 | 500 | 350 | 250 | 130 | 65 | 35 | 20 |
|----------------------|------|------|-----|-----|-----|-----|-----|----|----|----|
| Minimum NMOS | | | - | 4 | • | * | å | 2 | • | • |



COFFEE **B**REAK



